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PERSPECTIVE OPEN Straintronics with van der Waals materials

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With the outstanding mechanical properties, van der Waals (vdW) materials have attracted extensive attention in the research of straintronics in the past decade. In this perspective, we first review the recent progresses of the straintronics with vdW materials based on three different lattice deformation modes, i.e., in-plane strain, out-of-plane strain, and heterostrain. Then we discuss the current technique challenges in this field, and finally provide our perspectives on future research directions for both fundamental physics and electronic applications.

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Tuning electronic properties of materials lies at the heart of modern electronics. Strain engineering, as an efficient strategy to tune the electronic properties of materials and explore new quantum states in condensed matter physics, gives rise to an emerging research field referred as "straintronics". In the past few years, straintronics with van der Waals (vdW) materials has attracted lots of attention¹⁻¹¹. VdW materials usually possess extraordinary mechanical properties, such as large anisotropic compressibility and Young's modulus, providing a powerful knob for both exploring novel quantum states and developing new device functionalities based on strain engineering. In light of the layered structure, the strains acting on vdW materials are usually classified into in-plane type and out-of-plane type (Fig. 1), which are achieved by stretching the sample along the two-dimensional (2D) plane and compressing the sample perpendicularly to the 2D plane, respectively. Furthermore, stacking vdW materials into vertical heterostructures leads to a new type of strain engineering, i.e., heterostrain. Here, we briefly review the recent progresses of straintronics with vdW materials according to different modes of lattice deformation, and share our perspectives on future research directions in this field.

As the mostly studied type of strain on vdW materials, in-plane strain has been widely utilized to engineer the electronic band structure¹²⁻¹⁶ through changing the covalent bond lengths and angles within individual 2D layer. Especially, the band gap modification controlled by in-plane strain has been first proposed in graphene¹⁷, and then achieved in transition metal dichalco-genides (TMDs)¹⁸, black phosphorous¹⁹, etc. Besides, the deformation of in-plane lattice can also modulate the intralayer exchange energy²⁰ and spin-orbit coupling (SOC)²¹, enabling the strainassisted transition between different magnetic states in the vdW magnets²². One recent example is ultra-sensitive magnetization reversal assisted by in-plane strain in $Fe_2GeTe_3^{23}$, which indicates an alternative way to realize low-power magnetization switching in spintronic devices. In addition, transition from ferromagnetic state to antiferromagnetic state under in-plane strain in monolayer Crl₃ is also predicted^{24,25}, which requires more experimental efforts in the future. Another degree of freedom that could be adjusted by in-plane strain is the symmetry of crystal lattices. Especially, the rotational symmetry of vdW materials could be lowered if the in-plane strain is anisotropic, providing a unique approach to create the Berry curvature dipole and current induced magnetization in vdW materials with three-fold rotational symmetry, such as MOS_2^{26} , BiTel²⁷, etc. Moreover, in-plane strain could alter the topology of the quantum states that is correlated to the rotational symmetry, enabling the topological switching in vdW topological materials. At the current stage, vdW topological materials that could be investigated by applying in-plane strain include anomalous quantum Hall insulators such as $MnBi_2Te_4^{28}$ and magnetic twisted bilayer graphene^{29,30}, quantum spin Hall insulator such as undoped monolayer WTe_2^{31} , and 2D topological crystalline insulators such as monolayer IV–VI semiconductors³². Finally, in-plain strain could significantly modify the electronic correlation effects, resulting in metal-to-insulator transition, modulating the charge-density-wave, and tuning superconducting properties, etc. In particular, uniaxial in-plane strain has been proved to be an effective tool to explore the superconducting pairing symmetry³³, which could be utilized in vdW superconductors such as twisted bilayer graphene³⁴, twisted double bilayer graphene³⁵, monolayer NbSe₂³⁶, doped monolayer WTe₂³⁷, monolayer Fe(Te,Se)³⁸, and monolayer Bi₂Sr₂CaCu₂O_{8+δ}^{39,40}.

Compared to intralayer coupling, the interlayer coupling in vdW materials is relatively weak due to its vdW type. Many physical properties sensitive to the interlayer spacing have been engineered via the out-of-plane strain⁴¹. For example, out-of-plane strain can introduce positive piezoconductive effect in few-layer graphene, which is inaccessible through in-plane strain engineering⁴², and enhance the electrostatic potential from the substrate in graphene/hBN heterostructures, enabling the dynamical tuning of the band structure⁴³. Moreover, the reduction of interlayer spacing induced by out-of-plane strain in magic-angle twisted bilayer graphene successfully varies the interlayer hopping energy, leading to the shift of the magic angle for the superconducting and correlated insulating states⁴⁴. Other interlayer couplings that could be effectively modified by out-of-plane strain include interlayer exchange energy, which controls the interlayer magnetic order in few-layer Crl₃^{45,46}, and interlayer exciton binding energy that determines the excitonic/optoelectronic behaviors⁴⁷. Currently, the setup for applying out-of-plane strain on the vdW materials and heterostructures has already been well established. The future focus of out-of-plane strain engineering on vdW materials is twofold: exploring new states that are absent in ambient pressure, and understanding the mechanisms of novel interlayer effects. Here, examples of emergent interlayer effects include proximity spin-orbit coupling in graphene/TMDs heterostructures^{48,49}, in-plane orbital effect in twisted double

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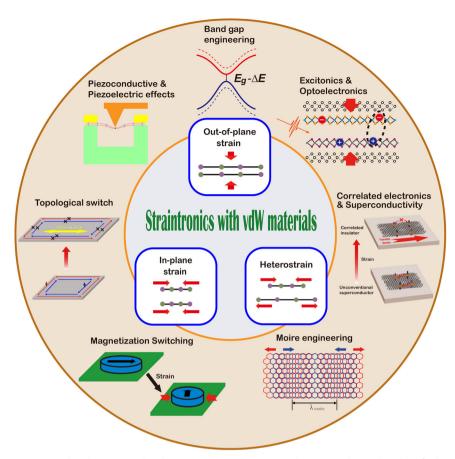


Fig. 1 Summary of straintronics with vdW materials. The strain engineering on vdW materials can be classified into in-plane strain, out-ofplane strain, and heterostrain. Related directions for the future research in this field are proposed.

bilayer graphene⁵⁰, unconventional ferroelectricity in moiré heterostructures^{51,52}, etc.

As a ubiquitous type of strain in vdW heterostructures, heterostrain arises when the adjacent 2D layers have unequal in-plane strains^{53–57}. On one hand, heterostrain inherits certain characteristics of in-plane strain, such as the capability of tuning intralayer hopping/exchange energy and breaking rotational symmetry. On the other hand, heterostrain also possesses many features similar to interlayer strain, since heterostrain could modulate the interlayer coupling by altering the relative displacement of the adjacent layers. Notably, the relative interlayer displacement can adjust the lattice mismatch of the adjacent layers, enabling the design of diverse moiré patterns by engineering the heterostrain. This moiré engineering promises a versatile platform for the exploration of correlated electronics and photonics in not only 2D moiré systems, but also one-dimensional moiré superlattices in twisted bilayer graphene or TMDs^{58,59}. Currently, heterostrain in vdW heterostructures is mainly generated by the inevitable thermal relaxation during the layer-stacking process, which leads to inhomogeneous and uncontrollable strain distribution. Such disorder of heterostrain distribution not only hinders the experimental investigation on the role of heterostrain engineering on correlated electronic behaviors in twisted bilayer graphene and TMDs, but also obstructs the extension of heterostrain engineering to other types of vdW heterostructures. To that end, developing new techniques to fabricate uniform and designable heterostrain in vdW heterostructures is one of the major challenges.

Another key challenge in this field is to develop fast and noninvasive methods to quantitatively characterize various types of strains in vdW materials, either naturally occurring or engineered. Compared to transmission electron microscopes (TEM) or scanning tunneling microscopy (STM), optical techniques such as Raman spectroscopy could provide more efficient and mild strategies, and have been widely used in characterizing in-plane strain in monolayer graphene^{60,61} and TMDs⁶². Therefore, extending those optical measurement techniques to the characterization of in-plane strain in more vdW materials and heterostrain in vdW heterostructures is urgently required.

To sum up, strain engineering provides powerful means for tailoring quantum and topological properties in vdW materials by directly modulating the interatomic distances and rotational symmetry. Meanwhile, the emergence of thousands of new vdW materials and heterostructures provides tremendous opportunities for the research of straintronics. Those materials that could be immediately investigated include vdW semiconductors for band gap engineering and piezoconductive/piezoelectric effects, heterostructures consisting of vdW semiconductors for excitonics/ optoelectronics, twisted bilayer graphene, or TMDs for moire engineering and correlated electronics/superconductivity, vdW magnetic materials for magnetization switching, vdW topological materials for topological switching, etc. Aside from the motivations of fundamental researches, other targets could be to develop new types of strain-assisted device functionality, such as data sensing based on excitonics/optoelectronics, logic operation based on band engineering and topological switching, data storing and computing based on magnetization switching, and eventually achieve strain-assisted in-sensor memory and insensor computing devices desirable for applications such as etextiles, e-tattoo, etc., in flexible electronics.

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COMPETING INTERESTS

The authors declare no competing interests.

ADDITIONAL INFORMATION

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